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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/633,644	08/07/2000	Yu-Kung Hsiao	TSMC2000-085	3337	
28112 75	90 11/25/2002				
GEORGE O. SAILE & ASSOCIATES			EXAMINER		
28 DAVIS AVENUE POUGHKEEPSIE, NY 12603 KANG, DONGHEE					
			ART UNIT	PAPER NUMBER	
			2811		
		DATE MAIL ED: 11/25/2002	DATE MAILED: 11/25/2002		

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No		Applicant(s)	- 16v-			
4	•							
	Office Action Summary	09/633,644		HSIAO ET AL.				
	Cinco Action Gammary	Examiner		Art Unit				
	The MAILING DATE of this communication app	Donghee Kang		2811				
Period fo	or Reply	lears on the cove	er sneet with the co	orresponaence ad	ddress			
THE I - External form of the control	ORTENED STATUTORY PERIOD FOR REPLY MAILING DATE OF THIS COMMUNICATION. nsions of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. period for reply specified above is less than thirty (30) days, a reply period for reply is specified above, the maximum statutory period were to reply within the set or extended period for reply will, by statute, reply received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, how within the statutory mit vill apply and will expire cause the application	vever, may a reply be time inimum of thirty (30) days s SIX (6) MONTHS from to the become ABANDONED	will be considered time the mailing date of this of	ly. communication.			
1)🖂	Responsive to communication(s) filed on 05 S	September 2002	•					
2a)⊠	This action is FINAL . 2b) ☐ Thi	is action is non-f	īnal.					
3) 🗌 Dispositi	Since this application is in condition for allowa closed in accordance with the practice under a con of Claims	nce except for f Ex parte Quayle	omal matters, pro , 1935 C.D. 11, 45	osecution as to th 53 O.G. 213.	ne merits is			
4)⊠	Claim(s) 1-15 is/are pending in the application	•						
	4a) Of the above claim(s) is/are withdraw	vn from consider	ration.					
	Claim(s) is/are allowed.							
	Claim(s) <u>1-15</u> is/are rejected.							
	Claim(s) is/are objected to.		•					
8)□	Claim(s) are subject to restriction and/or on Papers	election require	ment.					
	Γhe specification is objected to by the Examiner							
	The drawing(s) filed on is/are: a) accep		ed to by the Exam	iner				
	Applicant may not request that any objection to the		-					
11) 🔲 T	The proposed drawing correction filed on				er			
	If approved, corrected drawings are required in rep				.			
12) 🗌 T	he oath or declaration is objected to by the Exa	ıminer.						
Priority u	nder 35 U.S.C. §§ 119 and 120							
13) 🗌 .	Acknowledgment is made of a claim for foreign	priority under 35	5 U.S.C. § 119(a)-	(d) or (f).				
	☐ All b)☐ Some * c)☐ None of:		• (-,	(-) (-)				
	1. Certified copies of the priority documents	have been rece	ived.					
:	2. Certified copies of the priority documents			ı No.				
Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received.								
	cknowledgment is made of a claim for domestic				application)			
a)	☐ The translation of the foreign language prover the foreign lang	isional application	on has been recei	ved.	-ppiloution).			
Attachment(. ,						
2) Notice	of References Cited (PTO-892) of Draftsperson's Patent Drawing Review (PTO-948) ation Disclosure Statement(s) (PTO-1449) Paper No(s)	4)	Interview Summary (I Notice of Informal Pa Other:					
S. Patent and Trace TO-326 (Rev.		on Summary		Part of	Paper No. 8			

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DETAILED ACTION

Remarks

Applicant's Amendment and Response to Paper No.6 has been entered. Claims
 16-17 have been cancelled. Thus, claims 1-15 are pending in this application.

Drawings

2. The drawings are objected to under 37 CFR 1.83(a). The drawings must show every feature of the invention specified in the claims.

Therefore, the limitations claimed in claim 1 "an optical spacer" in line 11, "a second planarizing and/or patterned color filter" in lines 14-15, "a third planarizing spacer and/or patterned third color filter" in lines 16-17 must be shown or the feature(s) canceled from the claim.

The limitations claimed in claim 4 "a single overcoat layer comprises an antireflection coating" in line 1 must be shown or feature(s) canceled from the claim.

The limitations claimed in claim 6 "the overcoat layer comprises of a patterned multiplayer dielectric stack" in line 1 must be shown or feature(s) canceled from the claim. No new matter should be entered.

A proposed drawing correction or corrected drawings are required in reply to the Office action to avoid abandonment of the application. The objection to the drawings will not be held in abeyance.

Claim Objections

3. Claims **1, 4 & 6** are objected to because of the following informalities:

Regarding claim **1**:

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In line 9, the phrase "a patterned and encapsulated metal photoshield layer" should be "the patterned and encapsulated metal photoshield layer".

In line 11, the phrase "planarizing layer" should be "the planarizing encapsulant layer".

In line 13, the phrase "a first color filter layer" should be "the first patterned color filter layer".

In line 13, the phrase "a second planarizing" should be "a second planarizing layer".

In line 13, the phrase "patterned color filter layer" should be "patterned second color filter layer".

In line 16, the phrase "a second planarizing" should be "the second planarizing layer".

In line 16, "," after color filter layer should be deleted.

In line 16, the phrase "a third planarizing" should be "a third planarizing layer".

In line 19, the phrase "a third planarizing" should be "the third planarizing layer".

In line 22, the phrase "a micorlens layer" should be "the patterned microlens layer".

Regarding claim **4**:In line 1, the phrase "a single overcoat layer" should be "the overcoat layer".

Regarding claim **6**:In line 1, the phrase "the overcoat" should be "the overcoat layer".

Appropriate correction is required.

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Claim Rejections - 35 USC § 112

4. The following is a quotation of the first paragraph of 35 U.S.C. 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

5. Claims **1, 4, 6, 10, & 12** are rejected under 35 U.S.C. 112, first paragraph, as containing subject matter which was not described in the specification in such a way as to reasonably convey to one skilled in the relevant art that the inventor(s), at the time the application was filed, had possession of the claimed invention.

Regarding claim 1:

The specification does not support the limitations "forming upon an optical spacer and planarizing layer a first patterned color filter layer" (lines 11-12). The specification only describes color filter formed on the planarizing layer but not optical spacer (see Figs.4 & 5).

The specification does not support the limitations "forming upon a first color filter layer a second planarizing and/or patterned color filter layer" (lines 13-14).

The specification does not support the limitations "forming upon a second planarizing and/or color filter layer a third planarizing, spacer and/or patterned third color filter layer" (lines 16-17).

Regarding claim **4**:The specification does not support the limitation "a single overcoat layer comprises an antireflection coating layer" (line 1).

Regarding claim **6**:The specification does not support the limitation "the overcoat comprised of a patterned multilayer dielectric stack" (line 1).

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Regarding claim **10**:The specification does not support the limitation "the overcoat layer is exposed to ultraviolet or other irradiation to photopolymerize the material" (line 1).

Regarding claim **12**:The specification does not support the limitation "*ultraviolet*" or other irradiation is used to expose the overcoat layer…" (line 1).

Claims 2-3, 5, 7-9, 11, & 13-15 are rejected since each includes the limitations of independent claim 1.

Claim Rejections - 35 USC § 103

- 6. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 7. Claims **1-3 & 8** are rejected under 35 U.S.C. 103(a) as being unpatentable over Otsuka (US 6,040,591) in view of Baek (US 6,127,668) and further in view of Sano et al. (US 5,514,888).

Otsuka teaches a microelectronic method of fabricating a semiconductor color image device (Fig.5):

a silicon substrate (11) having a matrix of photodiode element (2) formed thereon; forming a metal photoshield layer (13) on the substrate, wherein the metal photoshield layer are periodically spaced to cover the areas between the photodiode elements; forming upon the patterned metal photoshield layer a first optically transparent planarizing encapsulant layer (14); forming upon the first optically

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transparent planarizing encapsulant layer a first color filter layer (15) registered with a subset of the photodiode elements; forming upon the first color filter layer a second planarizing layer (16); forming upon the second planarizing layer a patterned microlens layer (17); and forming upon the microlens (hemispherical convex) layer a transmittance overcoat layer (18) with a planar top surface. See also Col.3, line 56 – Col. 4, line 15.

Otsuka does not teach depositing a passivating coating encapsulating a metal photoshield layer. However, Baek teaches depositing a passivating coating (43) encapsulating a metal photoshield layer (42). See Fig.3c & Col.3, line 61 – Col.4, line 7.

Thus, it would have been obvious to one of ordinary skill in the art at the time the invention was made to incorporate the teaching of Baek into the Otsuka's device in order to protect the metal photoshield layer.

Neither Otsuka nor Baek teaches forming upon the second planarizing layer a third planarizing layer. Sano et al. teach a forming the third planarizing layer on the second planarizing layer (see Fig.1 & Col.1, line 39 – Col.9, line 35). Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to incorporate the teaching of Sano et al. into Otsuka's device as modified by Baek in order to optimize focal length of microlenz.

Response to Arguments

8. Applicant's arguments filed September 5, 2002 have been fully considered but they are not persuasive.

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Applicant argues that no special treatment or specified conditions are provided for adjustment of the planarizing spacer layer, nor are interface conditions between the color filter layers and planarizing spacer layer by cited prior arts. This is not convincing.

In response to applicant's argument that the references fail to show certain features of applicant's invention, it is noted that the features upon which applicant relies (e.g., for adjustment of the planarizing spacer layer & are interface conditions between the color filter layers and planarizing spacer layer) are not recited in the rejected claim(s). Although the claims are interpreted in light of the specification, limitations from the specification are not read into the claims. See *In re Van Geuns*, 988 F.2d 1181, 26 USPQ2d 1057 (Fed. Cir. 1993).

Conclusion

9. **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

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10. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Donghee Kang whose telephone number is 703-305-9147. The examiner can normally be reached on Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Tom Thomas can be reached on 703-308-2772. The fax phone numbers for the organization where this application or proceeding is assigned are 703-308-7722 for regular communications and 703-308-7722 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956.

DHK November 16, 2002

TOM THOMAS
SUPERVISORY PATENT EXAMINER
TECHNOLOGY CENTER 2800